# Monte Carlo Simulation of Phonon Transport

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# **IWCE 2012 Phonon School**





# **Outline**









# Silicon Nanowires – Efficient TE Materials



A. I. Hochbaum et al., Nature 451, 163 (2008).

# **Thermal Conductivity in Silicon Nanowires**



A. I. Hochbaum et al., Nature 451, 163 (2008).

# **Thermal Conductivity in Silicon Nanowires**



D. Li et al., Appl. Phys. Lett. 83, 2934 (2003).

# **Confined Acoustic Phonon Spectrum**



# Why confined ? Due to acoustic mismatch between Si and $SiO_2$ – severe when confined more

SiO<sub>2</sub> is acoustically soft Acoustic impedance  $\zeta = \rho v_s$  mismatch between Si & SiO<sub>2</sub> is ~40 %

#### Solve elastic continuum equation

with free-standing boundary conditions (**FSBC**):

normal component of stress tensor vanishes at interfaces

$$T_{ij}n_j\Big|_s=0$$

L.Donetti *et al.*, *J. App. Phys.* **100**, 013701 (2006) E.P. Pokatilov, *Phys. Rev. B* **72**, 113311 (2005) M.Dutta *et al.*, *Int. J. High Speed Electronics and Systems* **9**, 1 (1998) C.M. Sotomayor *et al.*, *Phys. Status Solidi C* **1**, 2609 (2004) (Experimental)

# **Confined Acoustic Phonons →Slower Phonons**



#### Flattened dispersion $\rightarrow$ lower group velocity

# **Confined Acoustic Phonons**



Phonon confinement insufficient to explain two orders of magnitude reduction in thermal conductivity

# **Thermal Conductivity – Roughness Dependence**



# Bulk Si $\rightarrow$ SiNWs : Two orders of magnitude reduction in thermal conductivity

A. I. Hochbaum et al., Nature 451, 163 (2008).

# **Simulator Flowchart – Thermal Conductivity**



# **Why Monte Carlo for Phonons**

 Normal (N) processes do not offer resistance because there is no change in direction

$$\vec{k}_1 + \vec{k}_2 \iff \vec{k}_3$$

 Umklapp (U) processes offer resistance to phonons because they turn phonons around

$$\vec{k}_1 + \vec{k}_2 \iff \vec{k}_3 \pm \vec{G}$$



N processes change the phonon distribution  $\rightarrow$  indirectly affect the thermal conductivity

# **Why Monte Carlo for Phonons**

Can treat the actual surface without using a specularity parameter.



A good way to capture phonon localization and the particular features of a given surface  $\leftarrow$  better than specularity parameter

# **Ensemble Monte Carlo Simulation**



# When solving the BTE – ensemble Monte Carlo (EMC) technique is the state-of-the-art

Utilizing random numbers to determine

- how long does a particle fly between scattering events
- what scattering mechanism to choose
- how to update momentum afterwards

Very robust and versatile

# **Dispersion Approximation**



# **Dispersion Approximation**



E. Pop et al., J Appl. Phys. 96, 4998 (2004)

# **Thermal Transport EMC**



Heat one end, let phonons diffuse, wait for steady state temperature gradient to be established, and from Fourier's law determine the thermal conductivity

R. B. Peterson, *J. Heat Transfer* **116**, 815 (1994)
S. Mazumder and A. Majumdar, *J. Heat Transfer* **123**, 749 (2001)
Lacroix *et al. Phys. Rev. B* **72**, 064305 (2005)

## **Phonon Initialization: Number of Phonons**



$$\langle n(\mathbf{q}, p, T) \rangle = \frac{1}{exp(\frac{\hbar\omega p, \mathbf{q}}{k_B T}) - 1}$$
  $N_w$  spectral intervals

$$N = V \sum_{p=LA,TA} \sum_{i=1}^{N_w} \left[ \frac{1}{exp(\frac{\hbar\omega_i}{K_B T}) - 1} \right] \frac{q_{i,p}^2}{2\pi^2 \upsilon_{i,p}} g_p \Delta \omega$$

10 x 10 x 10 nm<sup>3</sup> cell has ~ 10<sup>5</sup> phonons  $\tilde{N} = N/W_t$ .

E. B. Ramayya and I. Knezevic, Phys. Rev. B, submitted (2012)

# **Phonon Initialization: Phonon Attributes**

$$N = V \sum_{p=LA,TA} \sum_{i=1}^{N_w} \left[ \frac{1}{exp(\frac{\hbar\omega_i}{K_BT}) - 1} \right] \frac{q_{i,p}^2}{2\pi^2 \upsilon_{i,p}} g_p \Delta \omega$$

- Frequency
- Polarization
- Group Velocity
- Direction  $(q_x, q_y, q_z)$
- Position (x,yz)

Frequency is found from the cumulative number density function



scat

• Pick a random number R

 $F_{i-1} \leq R \leq F_i$ 

• Select  $\omega$  from the *i*<sup>th</sup> spectral interval

Polarization is found from the ratio of LA to TA phonons in a particular spectral interval

$$P_i(LA/TA) = \frac{N_i(LA)}{N_i(LA) + N_i(TA)}$$

• Pick a random number R

 $R < P_i(LA/TA)$ 

polarization p = LA else p = TA

### Phonon Initialization: Group Velocity and Wavevector

Group velocity and magnitude of wavevector can be found from the dispersion



$$\omega_q = \omega_o + v_s q + c q^2$$

# Direction of wavevector - isotropic

$$\hat{\mathbf{s}} = \begin{pmatrix} \sin \theta \cdot \cos \psi \\ \sin \theta \cdot \sin \psi \\ \cos \theta \end{pmatrix} \qquad \psi = 2 \pi R_2, \ \cos \theta = 2R_1 - 1$$

Phonons in a cell are distributed isotropically



 $R_1$ ,  $R_2$ , and  $R_3$  are random numbers  $L_x$ ,  $L_y$ , and  $L_z$  are dimensions of the device  $n_z$  is the number of cells

Energy of the cell should automatically be in accordance to the cell temperature

$$E = V \sum_{p=LA,TA} \sum_{i=1}^{N_w} \left[ \frac{\hbar \omega_i}{exp(\frac{\hbar \omega_i}{K_B T}) - 1} \right] \frac{q_{i,p}^2}{2\pi^2 \upsilon_{i,p}} g_p \Delta \omega$$

Check for consistency between N, E, and T
Find T from numerical inversion of E (of each cell) and check if it corresponds to the initialization temperature

- Let the phonons diffuse with the their initial velocities and track the position
- If the phonon crosses a cell delete it from that cell and assign the new cell number
- After each time step calculate the temperature from the net new energy of each cell
- If a phonon reaches an end cell delete it from the simulation domain
- Reinitialize the phonons in the end cells after each dt

# **Thermal Transport Ballistic Phonons**



Ballistic steady state temperature is given by the Stefan-Boltzmann law of blackbody radiation

$$T_{ss}^B = [(T_H^4 + T_L^4)/2]^{1/4}$$

# **Phonon Monte Carlo Transient Simulation**



- Phonon that underwent a scattering at the boundary is deleted and a new phonon is emitted from the boundary
- Direction of wavevector isotropic (normal to the surface)

$$\hat{\mathbf{s}} = \begin{pmatrix} \sin \theta \cdot \cos \psi \\ \sin \theta \cdot \sin \psi \\ \cos \theta \end{pmatrix} \qquad \begin{array}{l} \theta = \sin^{-1}(R_1) \\ \psi = 2\pi R_2 \end{array}$$

M. Modest, Radiative Heat Transfer p.654 (Academic Press, New York 2003)

- Phonon that underwent scattering is deleted and a new phonon is created from new distribution function weighted by the scattering rate
- Phonons that underwent a U scattering are replaced by phonons which have a new direction
- Phonons that underwent a N scattering are replaced by phonons with same direction but different magnitude.
- Phonon-impurity/isotope scattering is treated as isotropic

Frequency is found from the cumulative number density function weighted by scattering probability



Important for conserving the energy

# **Phonon Monte Carlo Transient Simulation**



E. B. Ramayya and I. Knezevic, Phys. Rev. B, submitted (2012)

Flux crossing two adjacent cells in steady state

$$\Phi = \frac{W_t}{dt} \sum_{i=1}^{N_c} \hbar \omega \frac{\mathbf{q}_z}{|q|}$$

Thermal conductivity is calculated from Fourier's law

$$\kappa = \frac{1}{A} \frac{\Delta L}{\Delta T} \Phi$$

# **Bulk Silicon Thermal Conductivity**



S. Mazumder and A. Majumdar, J. Heat Transfer 123, 749 (2001)

# **Limitation of Diffuse Boundary Scattering**



Lacroix et al. Appl. Phys. Lett. 89, 103104 (2006)

D. Li et al., Appl. Phys. Lett. 83, 2934 (2003)

# **Surface Roughness Inclusion in Monte Carlo**

Can treat the actual surface without using a specularity parameter.



A good way to capture phonon localization and the particular features of a given surface  $\leftarrow$  better than specularity parameter

## **Transient Results**



E. B. Ramayya and I. Knezevic, Phys. Rev. B, submitted (2012)

# **Thermal Conductivity: Roughness Dependence**



- κ<sub>I</sub> is more than an order of magnitude lower than that in bulk due to strong boundary scattering of phonons
- Decreases with increase in rms.

# **Thermal Transport Quasi-Balistic Phonons**



Increase the length



# Losing phonons

Bug in the code



# 10x phonon-phonon scattering

Losing phonons but not as much as before

Bug in the code



# Worse than before

Losing phonons

Only boundary scattering

Bug in the randomization after boundary scattering



Losing more phonons than that are injected

# **Thermal Conductivity: GaN**



GaN Nanowires for Thermoelectric Applications A. Davoody 3:30 Thursday

By changing the dispersion, the algorithm can be easily adapted to calculate the thermal conductivity of different semiconductors

# **Summary**

Monte Carlo simulation of phonon transport can be used to account for the large reduction in thermal conductivity in silicon nanowires

- Roughness inclusion as in electron transport
- Can be adapted to other semiconductors





#### References

- R. B. Peterson, *J. Heat Transfer* **116**, 815 (1994)
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J.-J. Wu, Tribol. Int. 33, 47 (2000)

S. M. Goodnick et al., Phys. Rev. B 32, 8171 (1985)

E. B. Ramayya and I. Knezevic, *Phys. Rev. B*, submitted (2012)